

Behaviors of optical and corrosion properties of *a*-C:H films at different thicknesses

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[Background] Recently, the *a*-C:H film was improved on properties such as optical, corrosion, mechanical and structure for high performance on applications in the industry. Especially, the both optical (refractive index (n) and extinction coefficient (k)) and corrosion properties were interested in research which are also controlled by sp^2 structure in the matrix. Besides, these properties are a function with a thickness of film. Therefore, the aim of this work was studied the behaviors of optical and corrosion properties of *a*-C:H films at different thickness.

[Experimental] The *a*-C:H film was deposited on *p*-type Si (100) substrates at different thicknesses by radio-frequency plasma-enhanced chemical-vapor-deposition technique (rf-PECVD) with 0.5 kV of bias voltage and 13.56 kHz of rf power, using benzene (C_6H_6) and hydrogen gas (H_2) as precursors. Raman spectroscopy are performed to characterize the chemical bonding information of *a*-C:H films. The optical properties of all films were investigated by spectroscopy ellipsometry (SE) method, which is non-destructive method. The corrosion behaviors of all samples were analyzed by electrochemical technique (potentiodynamic polarization) in air-saturated 3.5 wt.% NaCl solution for pH 2 at room temperature. In addition, the field-emission scanning electron microscopy (FE-SEM) has been used to study the surface of uncorroded and corroded regions.

[Results & Discussion] The Raman spectra displayed an asymmetric diamond-like peaks in the range of $1000-2000\text{ cm}^{-1}$, representative of *a*-C:H films; two broad peaks were detected, a D-band centered around $1374-1391\text{ cm}^{-1}$ and G-band centered around $1571-1577\text{ cm}^{-1}$. The decreasing of I_D/I_G ratio that it might indicated to the small sp^2 clusters in matrix. In addition, the n values had tendency increased whereas the behavior of k values had changed with thickness arise. The corrosion behavior of *a*-C:H films showed the corrosion potential (E_{corr}) and corrosion current density (I_{corr}) values as in the range of 201-289 mV and 1.9×10^{-4} to $9.96 \times 10^{-5}\text{ }\mu\text{A}/\text{cm}^2$, respectively, which is high society amorphous carbon materials, depended on sp^2 cluster into film. The corrosion rate of *a*-C:H films were less than uncoated sample. Here we presented to the corrosion types of *a*-C:H films as localized corrosion (pitting) which is one of the most corrosion aggressive as shown in Fig. 1. However, our *a*-C:H films indicated to high performance corrosion resistance in air-saturated 3.5 wt.% NaCl solution for pH 2; it also had protective efficiency as 98%-reach. Therefore, the optical and corrosion properties had changed that cause from different thickness of *a*-C:H films.

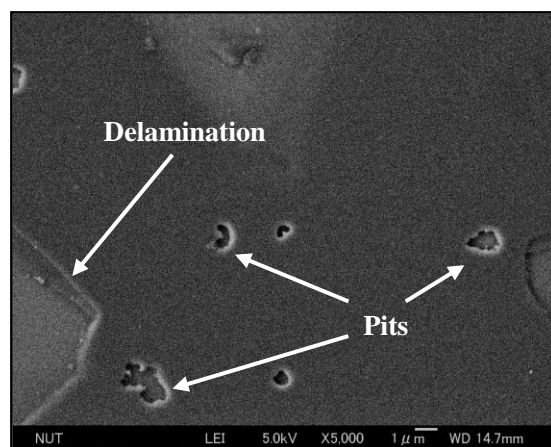


Fig. 1 FE-SEM image of localized corrosion on the surface of *a*-C:H films in 3.5 wt.% NaCl solution.